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SESAM fabrication errors and its influence on ultrafast laser cavity design

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Why we need to discuss SESAM fabrication error

- SESAM designs and manufacture errors will affect SESAM's optical behavior including GDD, modulation depth and saturantion fluence.
- SESAM's optical behavior will influence ultrafast laser's performance

Transfer Matrix Method will be used to analyze SESAM fabrication error

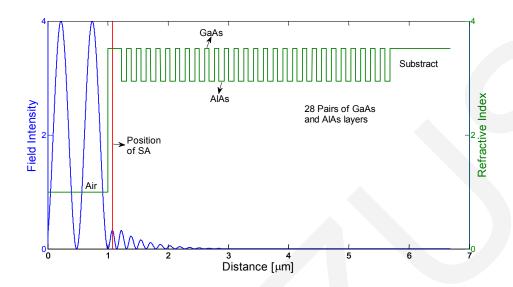
AIR
$$\begin{vmatrix} Aexp(-jk_1z) & Bexp(-jk_2z) & Cexp(-jk_3z) \\ A_1exp(-jk_1z) & B_1exp(-jk_2z) & C_1exp(-jk_3z) \end{vmatrix} ...$$

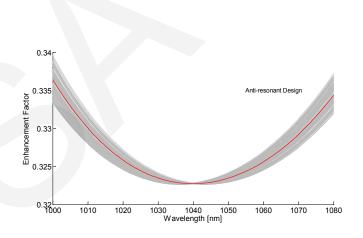
$$z=0 \qquad z=z_1 \qquad z=z_2 \qquad z=z_3$$

$$\begin{bmatrix} t \\ 0 \end{bmatrix} = \begin{bmatrix} M_{11} & M_{12} \\ M_{21} & M_{22} \end{bmatrix} \begin{bmatrix} 1 \\ r \end{bmatrix}$$

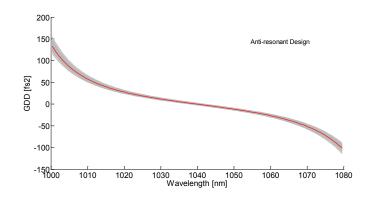
$$E(n) = E_1 \exp(-jk_n z) + E_2 \exp(jk_n z)$$

Anti-resonant SESAM

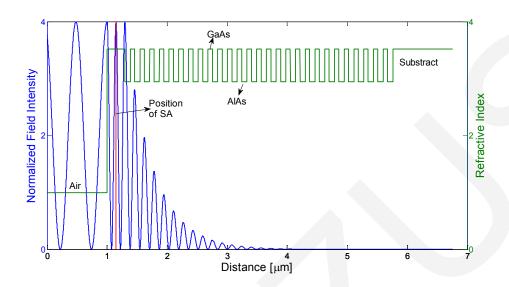


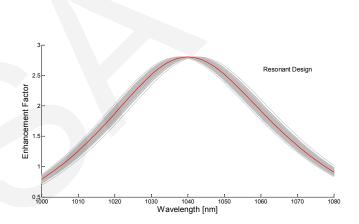


Anti-resonant SESAM structure and wavelength dependent enhancement factor change and GDD change. The red line represents the values for the designed structures assuming no growth errors; the gray lines are calculated with 1% random error for each layer.

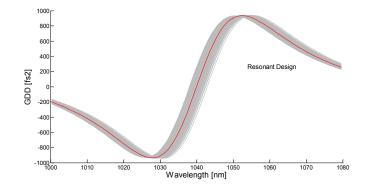


Resonant SESAM

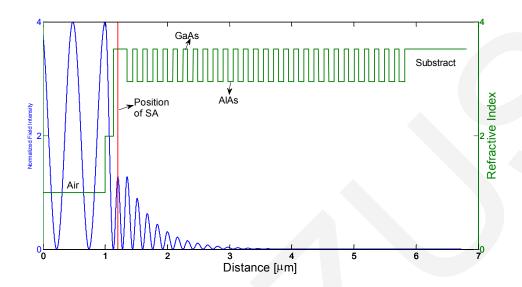




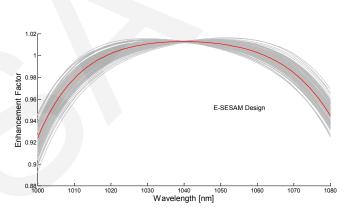
Resonant SESAM structure and wavelength dependent enhancement factor change and GDD change. The red line represents the values for the designed structures assuming no growth errors; the gray lines are calculated with 1% random error for each layer.

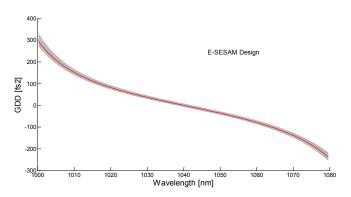


Enhanced SESAM

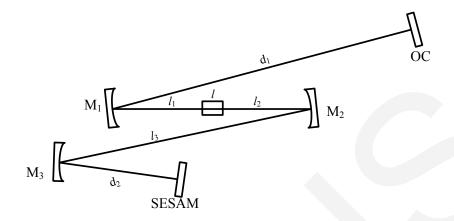


Enhanced SESAM structure and wavelength dependent enhancement factor change and GDD change. The red line represents the values for the designed structures assuming no growth errors; the gray lines are calculated with 1% random error for each layer.





Ultrafast laser cavity design to tolerate fabrication error



Laser running in cw mode locking range needs to satisfy:

$$F_{Q} = \frac{2q_{0}\tau_{A}F_{sat,L}A_{eff,L}}{T_{R}F_{sat,A}A_{eff,A}} < 1$$

$$F_{QM} = F_{sat,L} A_{sat,L} F_{sat,A} A_{sat,A} \Delta R / E_p^2 < 1$$

Laser cavity length, Laser beam diameter and SESAM beam diameter can be tuned to minimize SESAM's fabrication error influence on ultrafast laser's performance

Conclusion

- Fabrication thickness error will affect the characteristics of three SESAM structures: antiresonant SESAM, resonant SESAM and enhanced SESAM.
- 2. At the designed center wavelength, a fabrication error does not influence SESAM's modulation depth and saturation fluence that much for all three structures.
- 3. GDD value is affected a little more in resonant SESAM than in the other two. However if the SESAM is working at an off-center wavelength, the modulation depth error, saturation fluence error and GDD error increase.
- 4. When designing an ultrafast laser cavity which can tolerate a fabrication error, we should first avoid resonant SESAM, then select the right cavity length (or repetition rate), and make appropriate the curvatures of M₁, M₂, M₃ mirrors (beam sizes on SESAM and gain crystal), and the pumping level to operate the laser running in the CW mode-locking range.